

# Heta-Elisa Nieminen

## List of Publications by Year in descending order

Source: <https://exaly.com/author-pdf/7832575/publications.pdf>

Version: 2024-02-01

6

papers

79

citations

1684188

5

h-index

1872680

6

g-index

6

all docs

6

docs citations

6

times ranked

176

citing authors

#	ARTICLE	IF	CITATIONS
1	Atomic Layer Deposition of Photoconductive Cu <sub>2</sub> O Thin Films. ACS Omega, 2019, 4, 11205-11214.	3.5	40
2	Intercalation of Lithium Ions from Gaseous Precursors into $\hat{1}^2\text{-MnO}_2$ Thin Films Deposited by Atomic Layer Deposition. Journal of Physical Chemistry C, 2019, 123, 15802-15814.	3.1	11
3	Synchronizing gas injections and time-resolved data acquisition for perturbation-enhanced APXPS experiments. Review of Scientific Instruments, 2021, 92, 044101.	1.3	11
4	Ambient pressure x-ray photoelectron spectroscopy setup for synchrotron-based <i>in situ</i> and <i>operando</i> atomic layer deposition research. Review of Scientific Instruments, 2022, 93, 013905.	1.3	9
5	<i>In Situ</i> Reaction Mechanism Study on Atomic Layer Deposition of Intermetallic Co <sub>3</sub> Sn <sub>2</sub> Thin Films. Chemistry of Materials, 2020, 32, 8120-8128.	6.7	6
6	Reaction mechanism studies on atomic layer deposition process of AlF <sub>3</sub> . Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2022, 40, .	2.1	2